Taw Kuei Chan

List of Publications by Year in descending order

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		687363	580821
29	599	13	25
papers	citations	h-index	g-index
30	30	30	1203
all docs	docs citations	times ranked	citing authors

#	Article	IF	Citations
1	Magnetism in MoS2 induced by proton irradiation. Applied Physics Letters, 2012, 101, .	3.3	205
2	The effect of layer number and substrate on the stability of graphene under MeV proton beam irradiation. Carbon, 2011, 49, 1720-1726.	10.3	86
3	Mega-electron-volt proton irradiation on supported and suspended graphene: A Raman spectroscopic layer dependent study. Journal of Applied Physics, 2011, 110, .	2.5	56
4	Tuning the Interface Conductivity of LaAlO ₃ /SrTiO ₃ Using Ion Beams: Implications for Patterning. ACS Nano, 2013, 7, 10572-10581.	14.6	34
5	Compositional dependence of optical critical point parameters in pseudomorphic GeSn alloys. Journal of Applied Physics, 2014, 116, 053520.	2.5	25
6	Formation of epitaxial metastable NiGe2 thin film on Ge(100) by pulsed excimer laser anneal. Applied Physics Letters, 2010, 97, .	3.3	20
7	The CIBA high resolution RBS facility. Nuclear Instruments & Methods in Physics Research B, 2006, 249, 915-917.	1.4	19
8	Gradient inverse opal photonic crystals via spatially controlled template replication of self-assembled opals. Nanoscale, 2011, 3, 4951.	5.6	19
9	Strained SiGeSn formed by Sn implant into SiGe and pulsed laser annealing. Applied Physics Letters, 2007, 91, 202105.	3.3	15
10	Synthesis of embedded Au nanostructures by ion irradiation: influence of ion induced viscous flow and sputtering. Beilstein Journal of Nanotechnology, 2014, 5, 105-110.	2.8	15
11	Structural, magnetic, and transport investigations of CrTe clustering effect in (Zn,Cr)Te system. Journal of Applied Physics, 2007, 102, .	2.5	14
12	lon beam studies of Hafnium based alternate high-k dielectric films deposited on silicon. Nuclear Instruments & Methods in Physics Research B, 2014, 332, 389-392.	1.4	14
13	Ion induced intermixing and consequent effects on the leakage currents in HfO2/SiO2/Si systems. Applied Physics A: Materials Science and Processing, 2017, 123, 1.	2.3	14
14	Towards simultaneous achievement of carrier activation and crystallinity in Ge and GeSn with heated phosphorus ion implantation: An optical study. Applied Physics Letters, 2014, 105, 122108.	3.3	12
15	Single Crystalline Germanium-Lead Alloy on Germanium Substrate Formed by Pulsed Laser Epitaxy. ECS Solid State Letters, 2014, 3, P91-P93.	1.4	12
16	Lu2O3â^•Al2O3 gate dielectrics for germanium metal-oxide-semiconductor devices. Applied Physics Letters, 2008, 93, 062901.	3.3	9
17	Formation of nanoclusters with varying Pb/Se concentration and distribution after sequential Pb+ and Se+ ion implantation into SiO2. Nuclear Instruments & Methods in Physics Research B, 2012, 273, 199-202.	1.4	6
18	Interface strain study of thin Lu2O3/Si using HRBS. Nuclear Instruments & Methods in Physics Research B, 2008, 266, 1486-1489.	1.4	5

#	Article	IF	CITATIONS
19	Ion beam-mixing effects in nearly lattice-matched AllnN/GaN heterostructures by swift heavy ion irradiation. Radiation Effects and Defects in Solids, 2012, 167, 506-511.	1.2	4
20	Loss of implanted heavy elements during annealing of ultra-shallow ion-implanted silicon: The complete picture. Applied Surface Science, 2014, 314, 322-330.	6.1	4
21	HRBS/channeling studies of ultra-thin ITO films on Si. Nuclear Instruments & Methods in Physics Research B, 2008, 266, 1464-1467.	1.4	3
22	Lanthanide-based graded barrier structure for enhanced nanocrystal memory properties. Applied Physics Letters, 2009, 95, 113113.	3.3	3
23	Solid phase epitaxy of ultra-shallow Sn implanted Si observed using high-resolution Rutherford backscattering spectrometry. Applied Physics Letters, 2012, 101, 081602.	3.3	2
24	Realization of Silicon-Germanium-Tin (SiGeSn) Source/Drain Stressors by Sn implant and Solid Phase Epitaxy for strain engineering in SiGe channel P-MOSFETs., 2008,,.		1
25	Sub-100keV ion beam generation with a Van De Graaff accelerator using an external DC voltage supply. Nuclear Instruments & Methods in Physics Research B, 2011, 269, 2699-2702.	1.4	1
26	Reduced Contact Resistance and Improved Surface Morphology of Ohmic Contacts on GaN Employing KrF Laser Irradiation. Japanese Journal of Applied Physics, 2011, 50, 04DF06.	1.5	1
27	Channeling contrast microscopy of epitaxial lateral overgrowth of ZnO/GaN films. Nuclear Instruments & Methods in Physics Research B, 2007, 260, 299-303.	1.4	O
28	Electrochemical Anodization of Silicon-on-Insulator Wafers Using an AC. Electrochemical and Solid-State Letters, 2010, 13, H271.	2.2	0
29	Germanium-lead alloy with 0.3% substitutional lead formed by pulsed laser induced epitaxy. , 2014, , .		O